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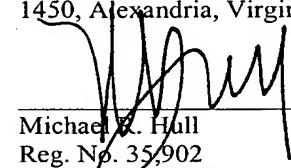
1752
PATENT
30205/37675



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Keun Kyu Kong et al.)
Serial No.: 10/006,633)
Filed: December 5, 2001)
For: Pattern Width Slimming-)
Inhibiting Method of Photoresist Pattern)
Using Photoresist Composition)
Containing Thermal Acid Generator)
Group Art Unit: 1752)
Examiner: Amanda C. Walke)

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on **February 5, 2004**, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450


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AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

This paper is filed in response to the office action mailed on November 5, 2003. Please amend the above-identified patent application as follows: